



# GENERATING COMPLEX STRUCTURES IN GLASS THROUGH SELECTIVE LASER-INDUCED ETCHING

# Task

To micro-structure dielectrics, such as glass and crystals, mask-based and impressing processes as well as direct ablation are commonly used today. These processes are confined, however, on account of their limited ability to produce undercuts, pre-assembled components or internal cavities. In contrast, the simplified manufacture of such structures directly from CAD data (Digital Photonic Production) opens up new possibilities to fabricate micro-fluidics or assembled micro-mechanisms. Selective laser-induced etching is a process that is suited to producing 3D structures in glass.

# Method

Selective laser-induced etching (SLE) is a two-stage process. In the first step, the transparent material is modified by the laser radiation. To do this, ultra-short pulsed laser radiation is focused into the inside of the workpiece (ø 1 - 2  $\mu$ m). As the beam focus moves, a continuous volume is modified, which has a contact to one of the outer surfaces. In the second step, the modified material is removed by wet-chemical etching. To produce complex component parts with digital photonic production, our software routine automatically creates the

- 1 Micro-channel bridge inside a biochip.
- 2 Double-helical planetary transmission in quartz glass.

track data derived from digital CAD data. The laser beam is deflected by the micro-scanner system, thereby exposing the glass according to the track data. The micro-scanner system and the component parts are available commercially from the spin-off company LightFab.

### Result

It is now possible to manufacture a mounted, double-helical planetary transmission in quartz glass. The diameter of the demonstration model is 10 mm. A possible drive can occur through a six-round formed drill hole in the sun gear (Figure 2). Microfluidics with features of 3-dimensional geometry, such as bridging in micro-channels, enable a larger functional integration density for lab-on-chip applications (Figure 1).

# **Applications**

Users for the newly developed processes come from microsystem technology, bio- and medical technology, as well as chemical analysis and process technology.

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